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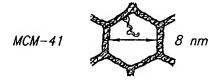
FIG. 1a SUB-NANOPOROUS ZEOLITES : < 1nm

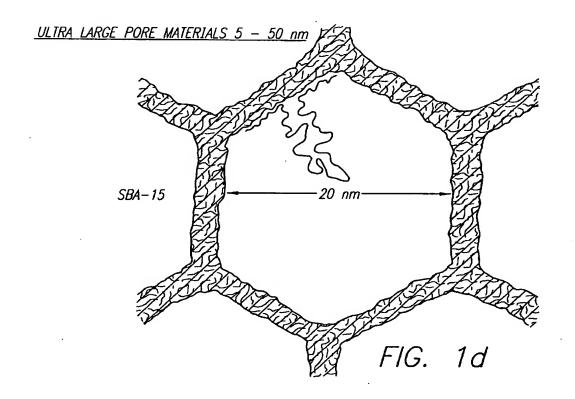
FAUJASITE (B)



FIG. 1b

FIG. 1c MESOPOROUS MOLECULAR SIEVES: 2- 10 nm





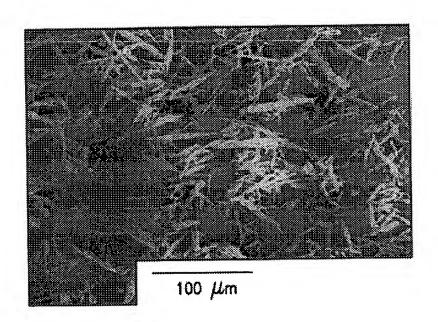


FIG. 3a

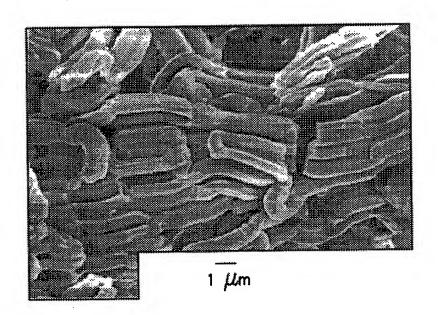


FIG. 3b

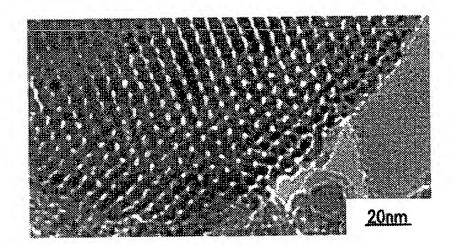


FIG. 3c

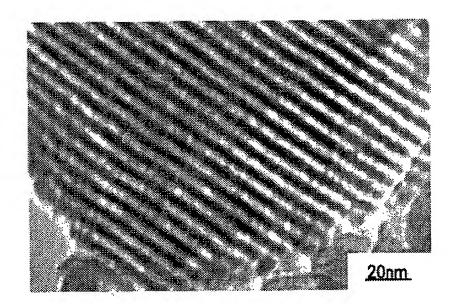


FIG. 3d

FIG. 4a

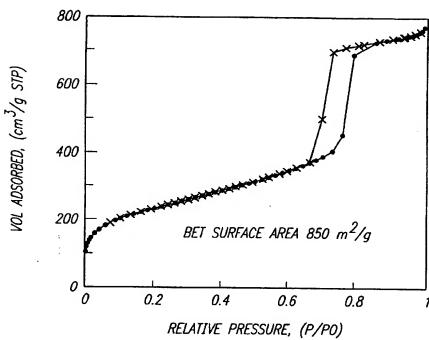


FIG. 4b

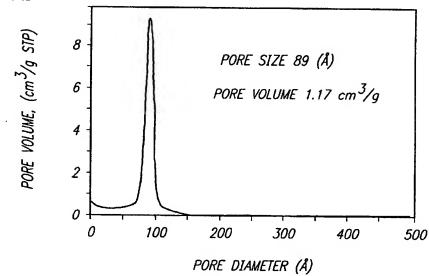


FIG. 4C

1500

PORE SIZE 260 Å

PORE VOLUME 2.2 cm³/g

BET SURFACE AREA 910 m²/g

0 0.2 0.4 0.6 0.8 1

RELATIVE PRESSURE, (P/P0)

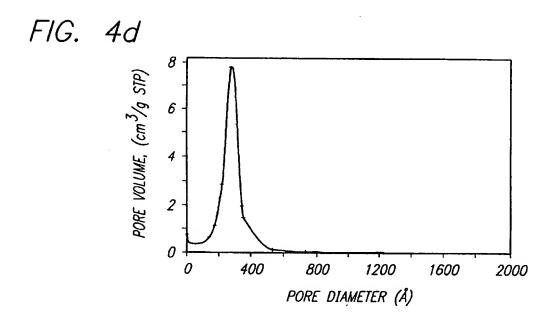


FIG. 5b FIG. 5a 20nm 20nm FIG. 5d FIG. 5c 25nm

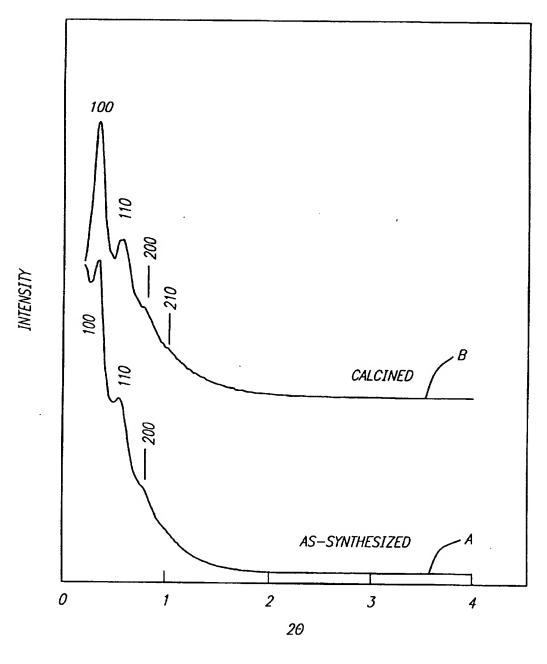
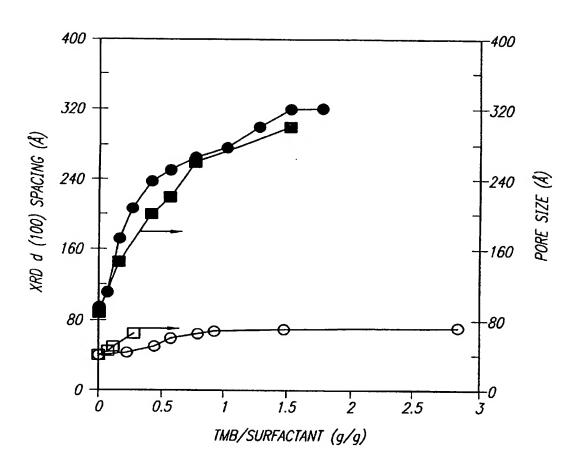


FIG. 6

FIG. 7



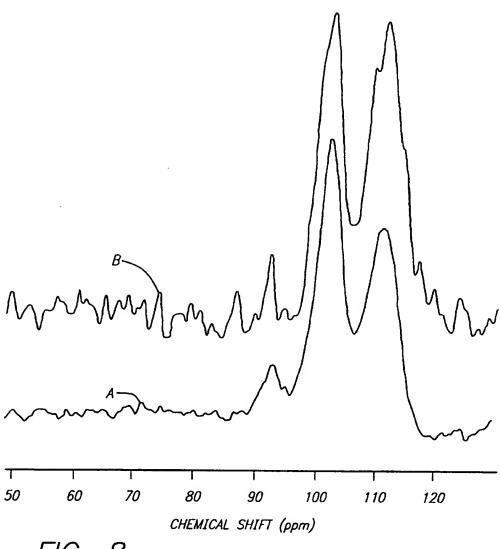
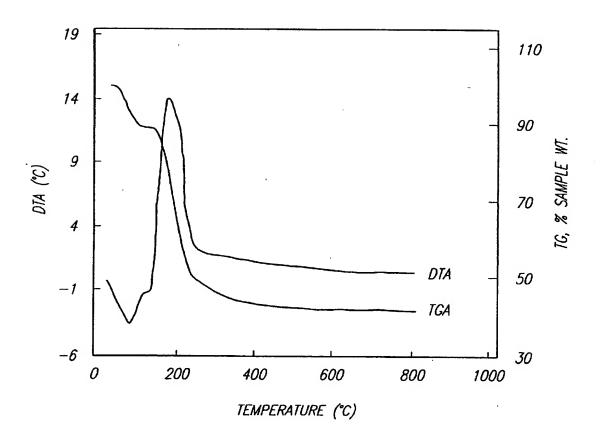


FIG. 8

FIG. 9



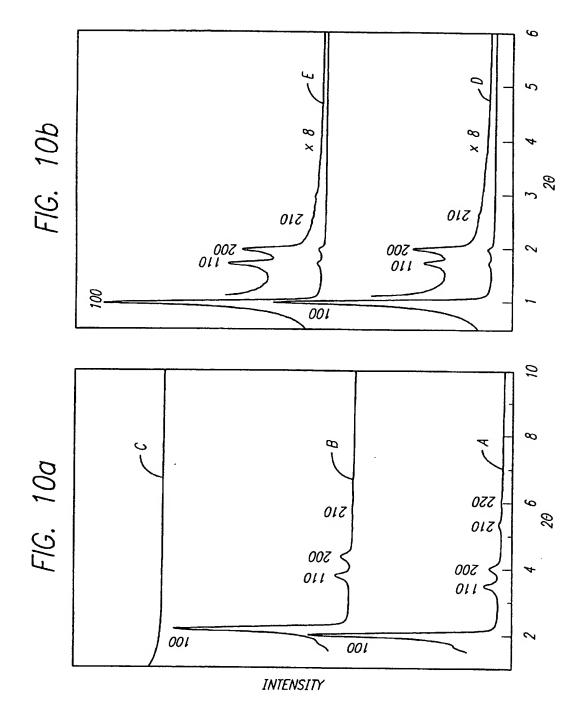


FIG. 11a

Electrical to each person of an exact with or a training and the compensatures are a compensatures as a compensature of a proved provided a compensature with order a lower mean residence.

FIG. 11b

temperatures at temperatures at temperatures. However, feduose of improve of Hostatec will such a lower to suc

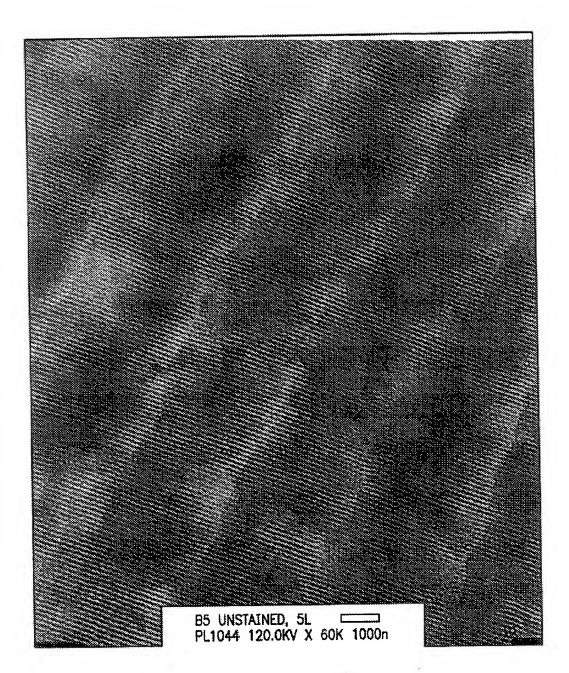


FIG. 12

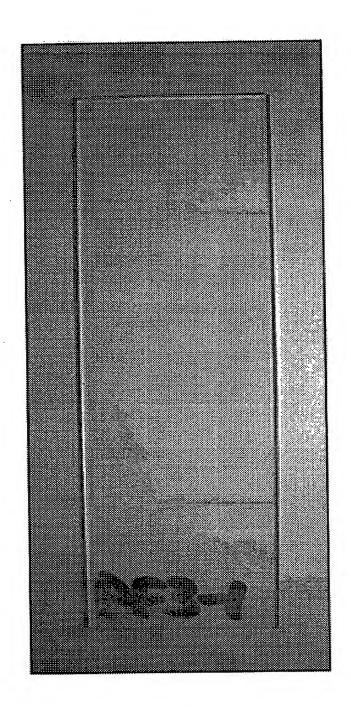


FIG. 13a

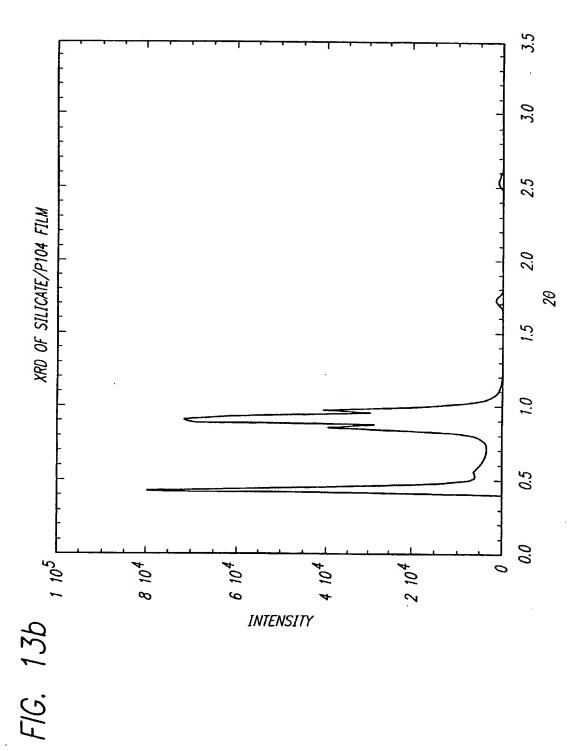


FIG. 14

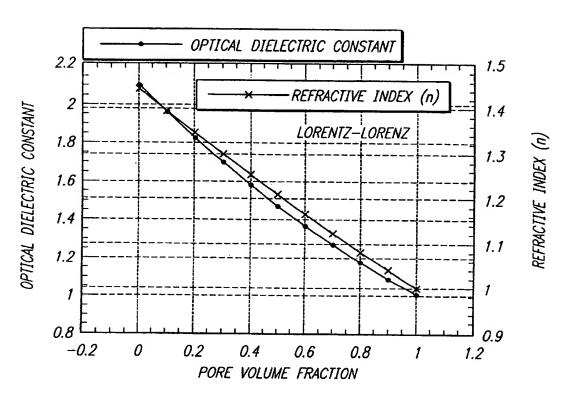
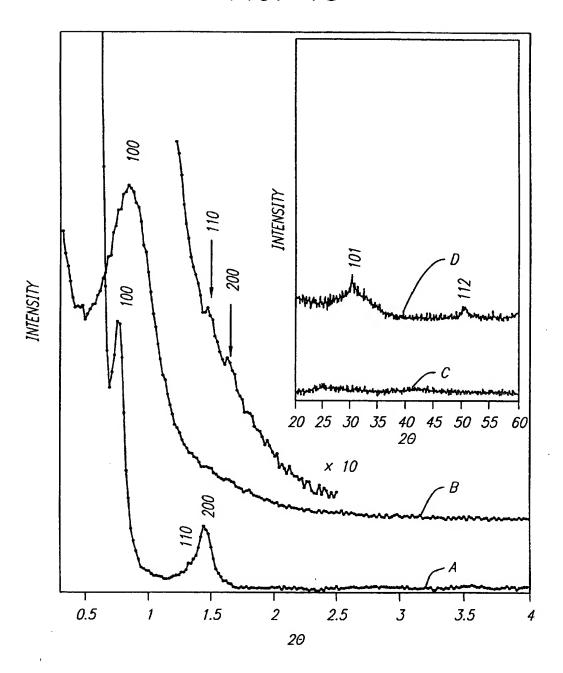
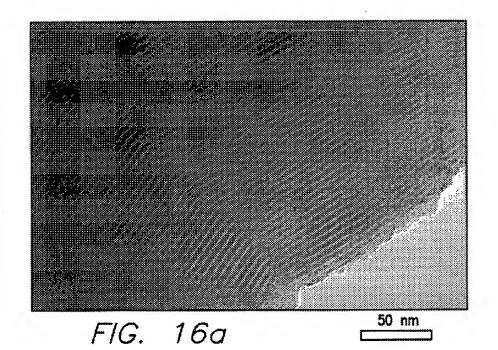


FIG. 15





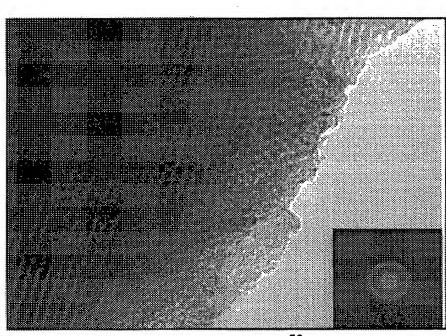


FIG. 16b

50 nm

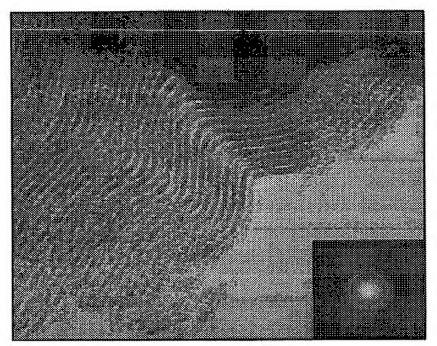


FIG. 17a

20 nm

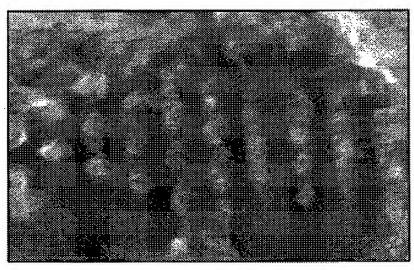
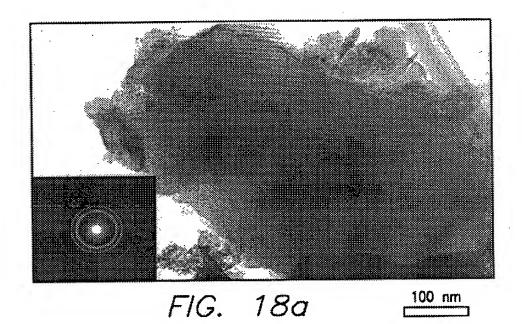
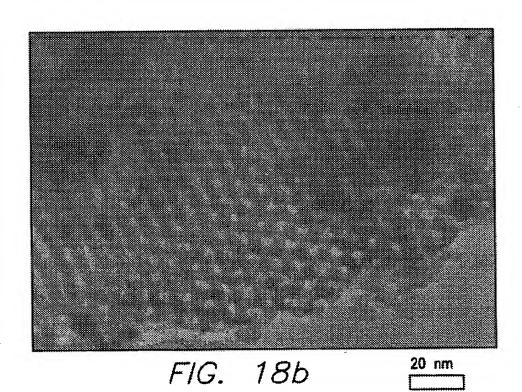


FIG. 17b

20 nm





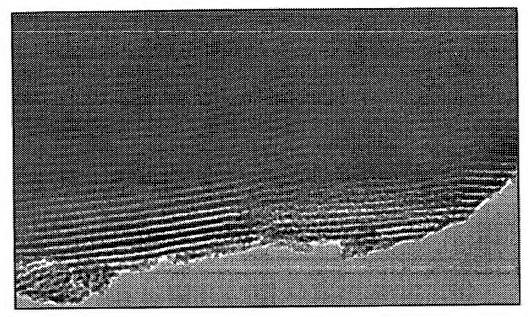


FIG. 19a

100 nm

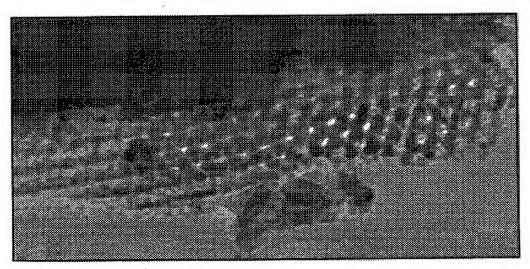


FIG. 19b

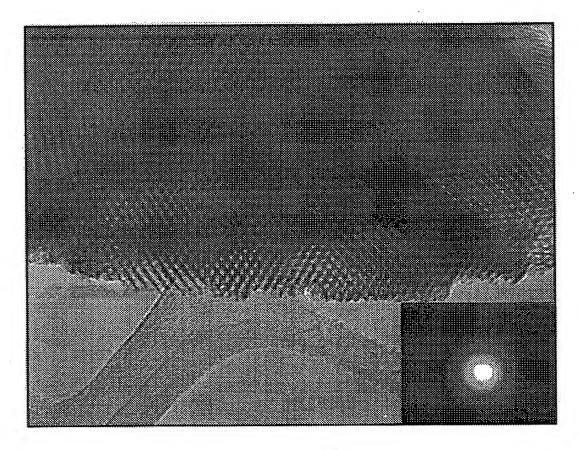


FIG. 20

20 nm

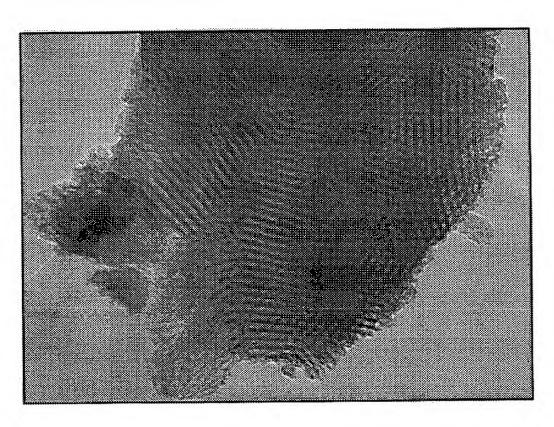


FIG. 21

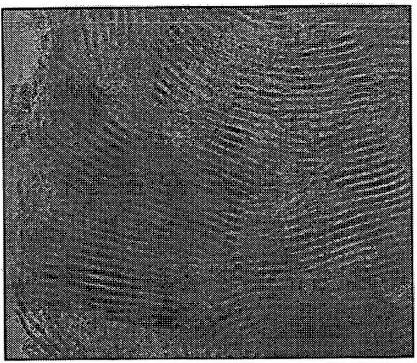


FIG. 22a

100 nm

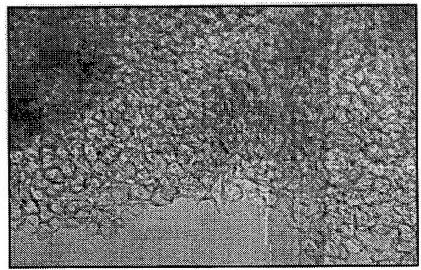


FIG. 22b

50 nm



FIG. 23

50 nm

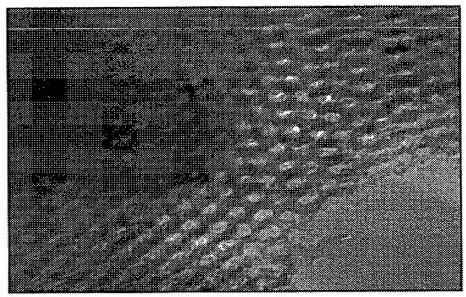


FIG. 24a

20 nm

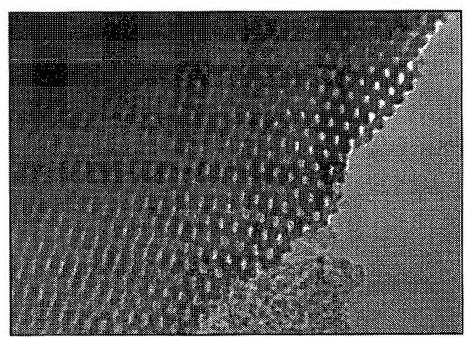


FIG. 24b

50 nm

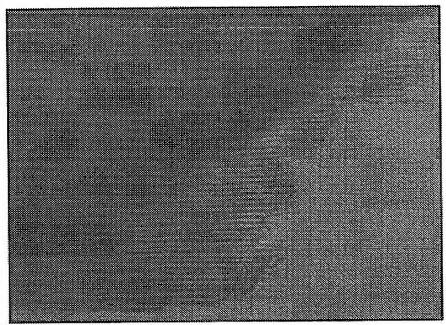


FIG. 25a

50 nm



FIG. 25b

50 nm

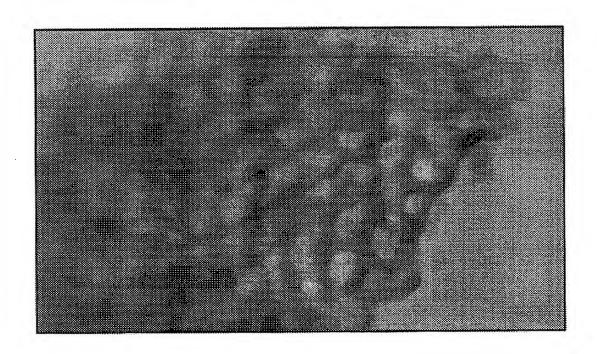


FIG. 26

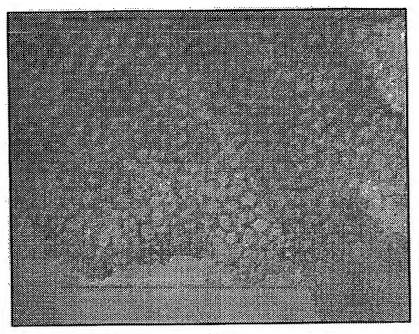


FIG. 27a 20 nm

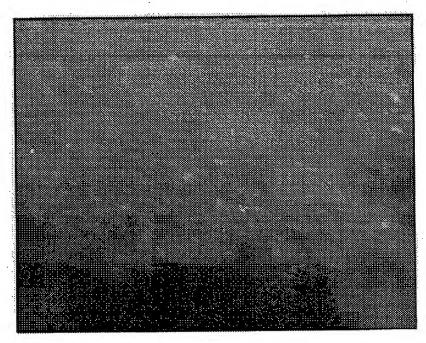


FIG. 27b = 20 nm

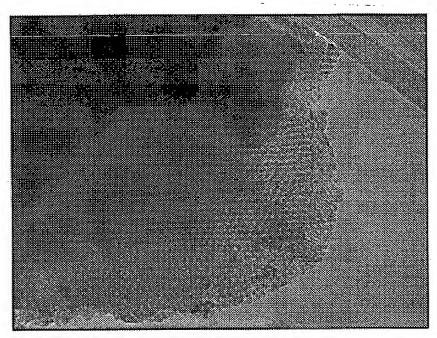


FIG. 28a

50 nm

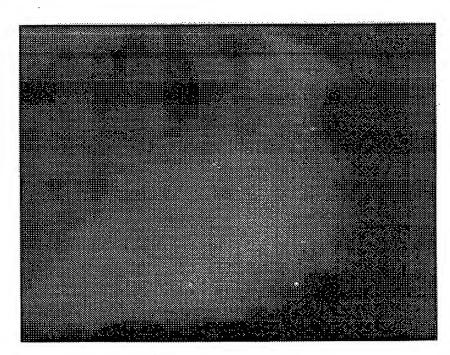
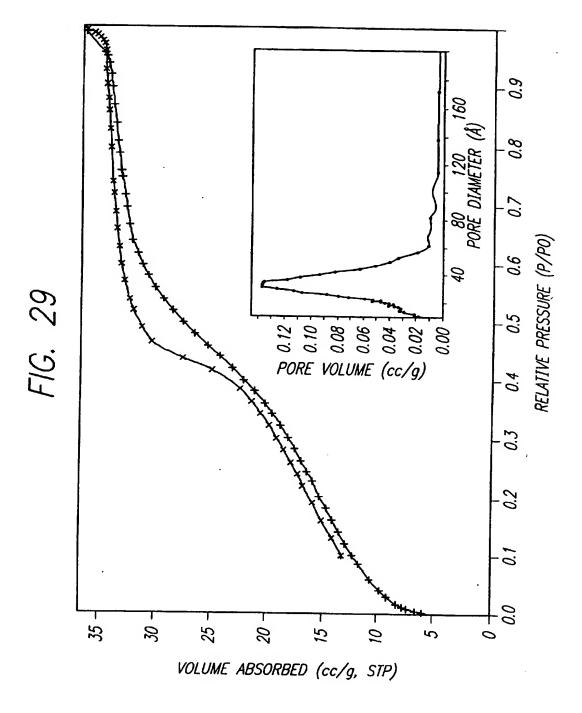
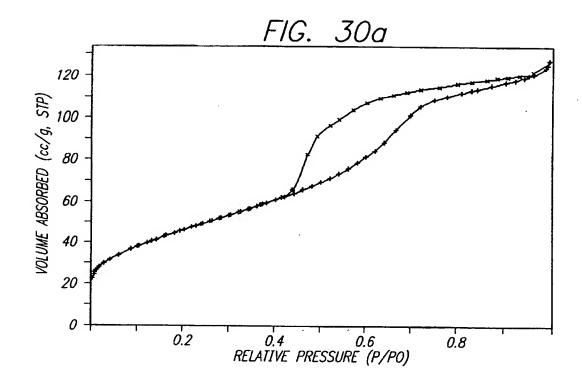
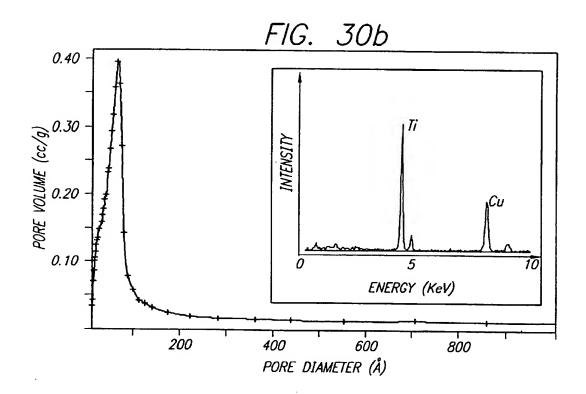
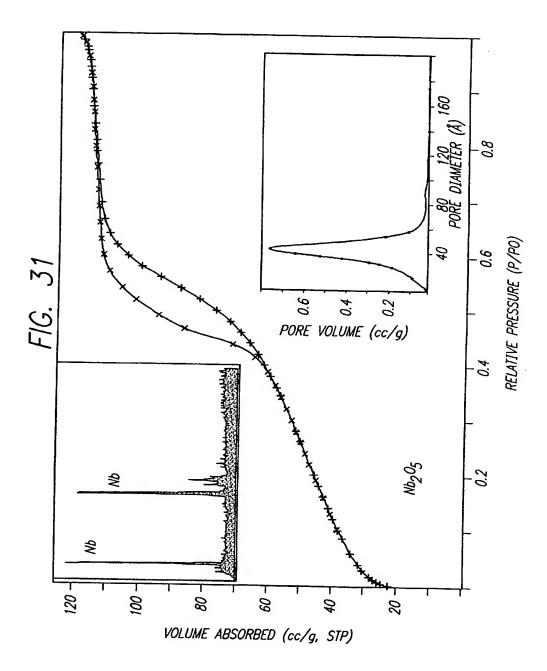


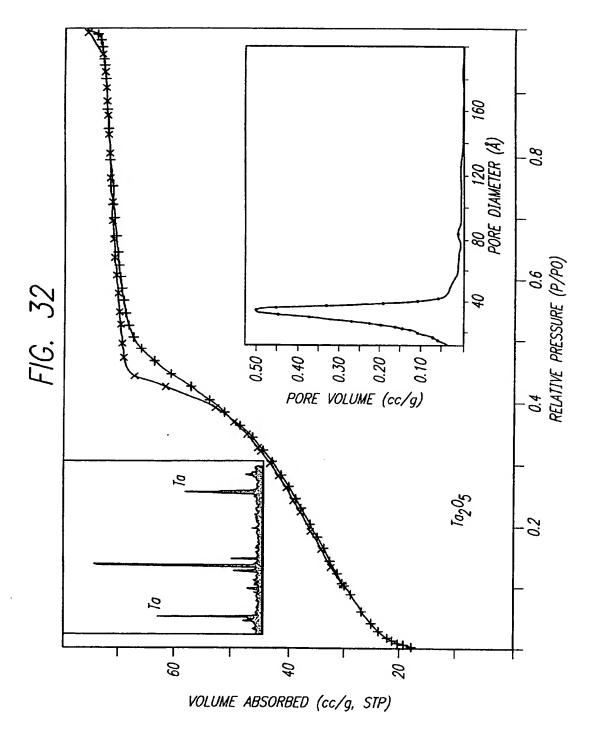
FIG. 28b

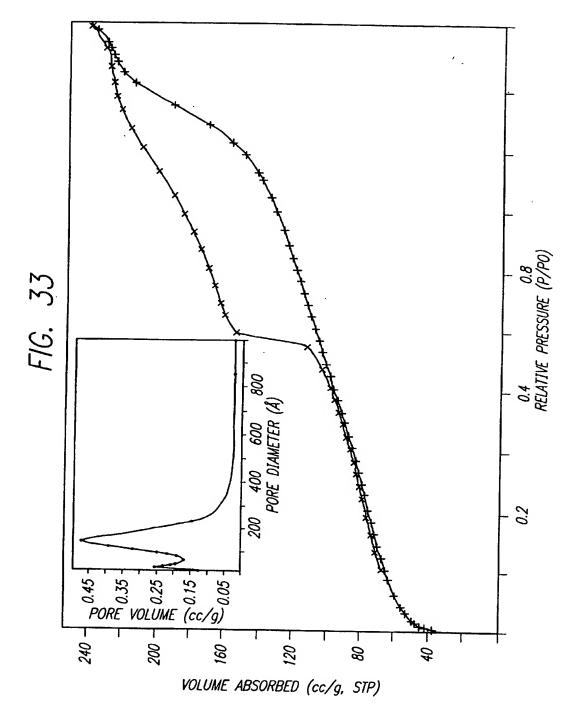












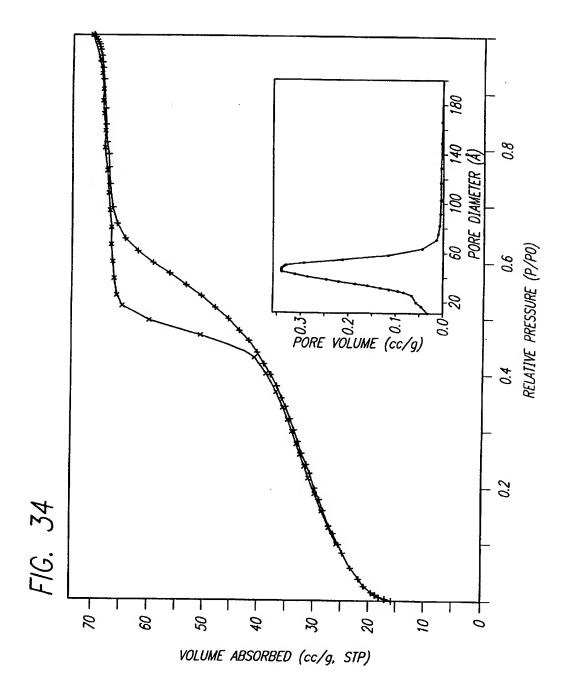


FIG. 35a

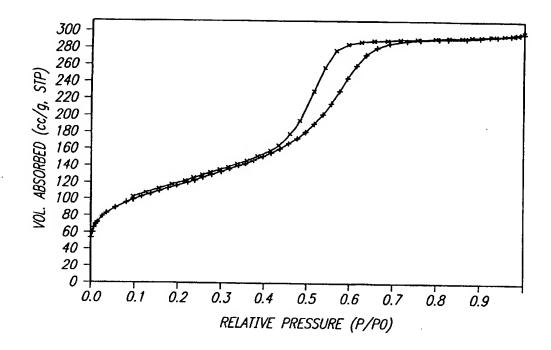


FIG. 35b

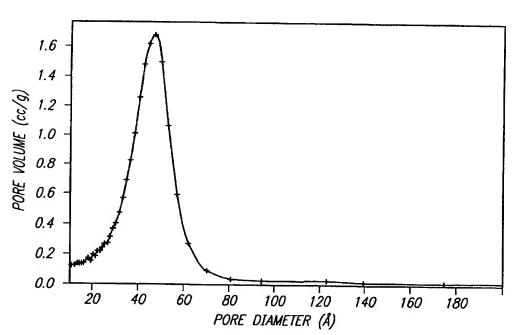
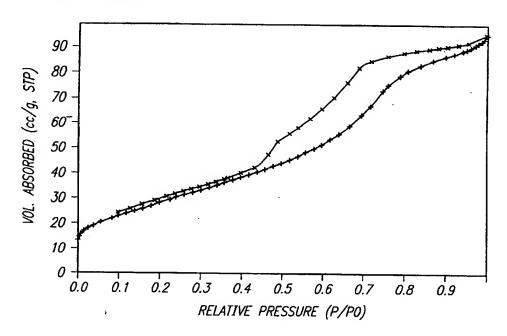


FIG. 36a



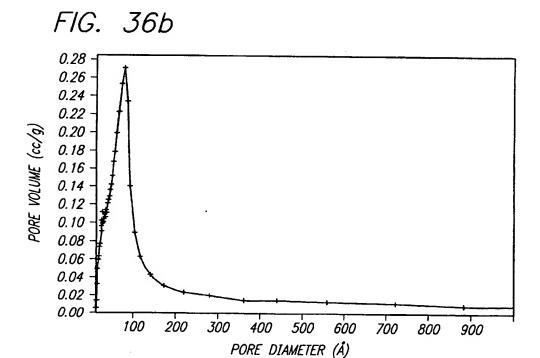
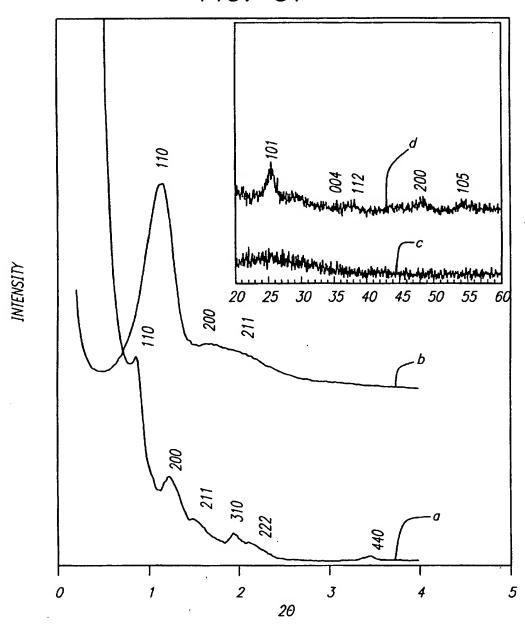


FIG. 37



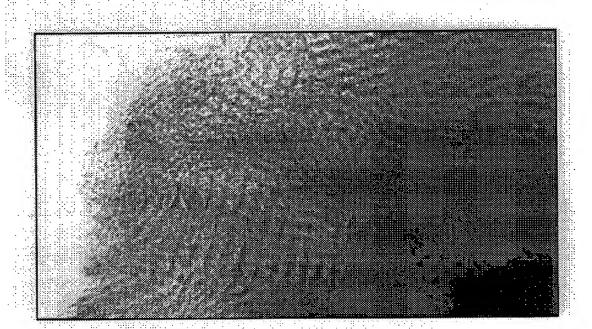


FIG. 38

20 nm

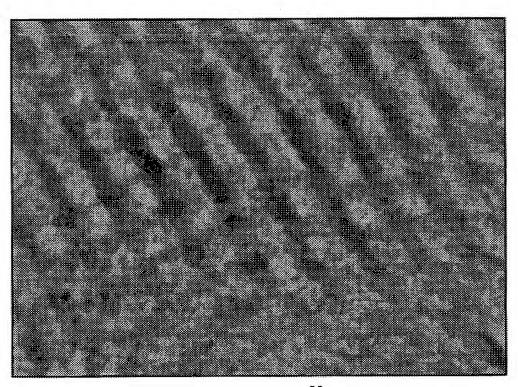


FIG. 39

20 nm

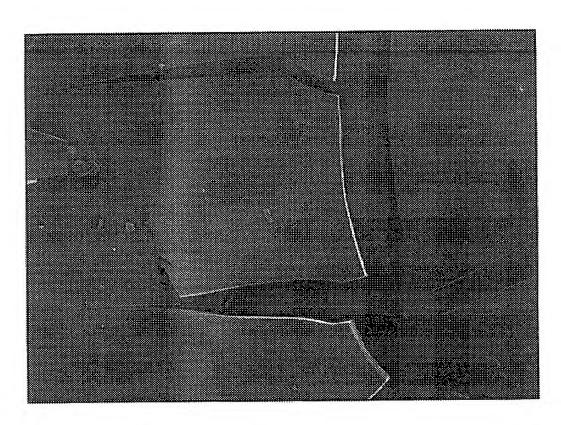


FIG. 40 10 μm

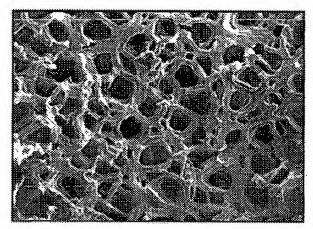


FIG. 41a

10 µm
0 kV x 3.000 12mm

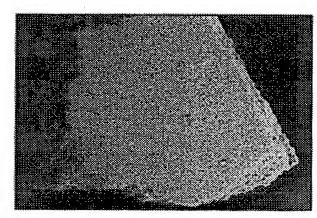
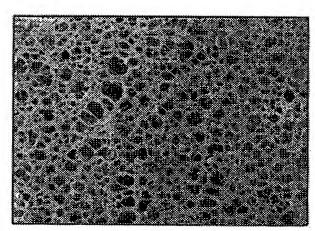


FIG. 41b



F/G. 41c

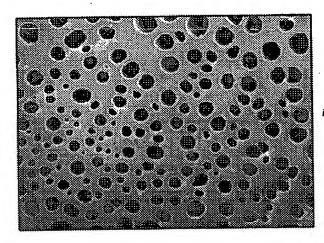


FIG. 41d 10 μm 3.0 kV x 1.300 10mm

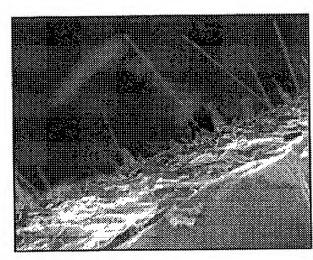
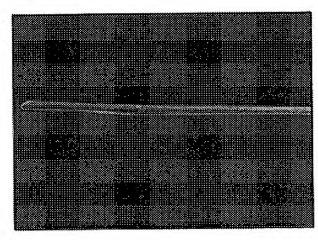
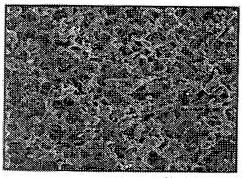


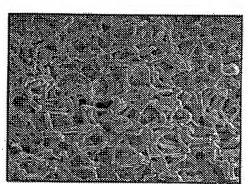
FIG. 41e
= 10 μm



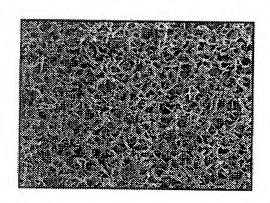
F/G. 41f 1 μm 3.0 kV x 5.500 11mm



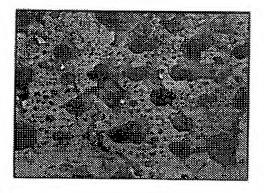
JEOL $\frac{10 \ \mu_{\rm m}}{3.0 \ {\rm kV} \ {\rm X} \ 2.530} \frac{12 \ {\rm mm}}{12 \ {\rm mm}}$ $F/G. \ 42a$



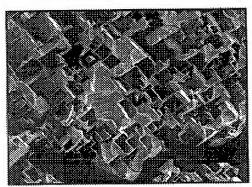
- 1 μm 3.0 kV X 5.000 12mm FIG. 42b



 $\frac{10 \, \mu_{\rm m}}{3.0 \, \text{kV} \, \text{X} \, 2,700 \, 11 \text{mm}}$ FIG. 42c

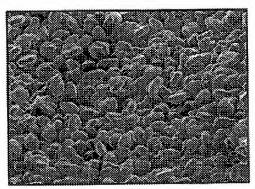


JEOL 3.0 kV X 160 1.1 mm F/G. 42d



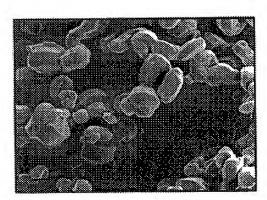
— 10 μm 3.0 kV X .550 12mm

FIG. 43a

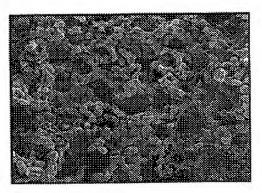


— 10 μm 3.0 kV X 1.500 11mm

FIG. 43b

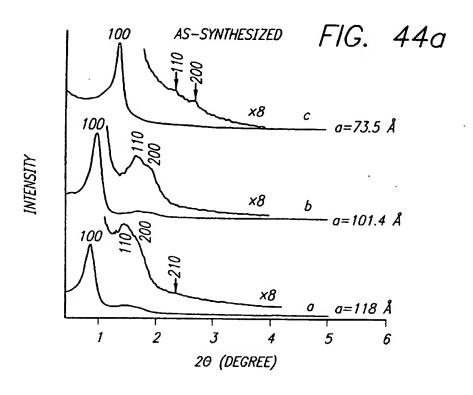


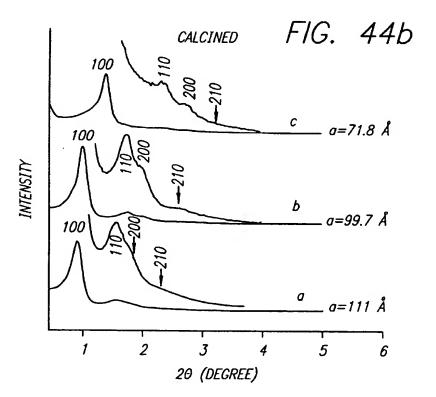
 $-1 \mu m$ 3.0 kV X 5.000 12mm

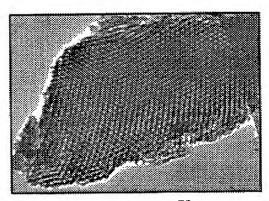


--- 10 μ m 3.0 kV X 1.100 11mm

FIG. 43c FIG. 43d







50 nm

FIG. 45a



100 nm

FIG. 45b

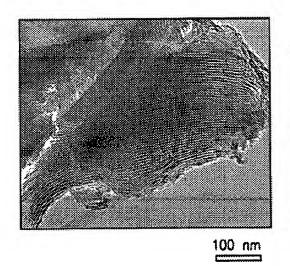
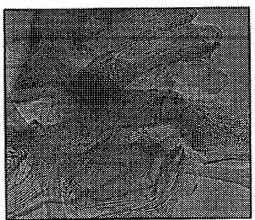
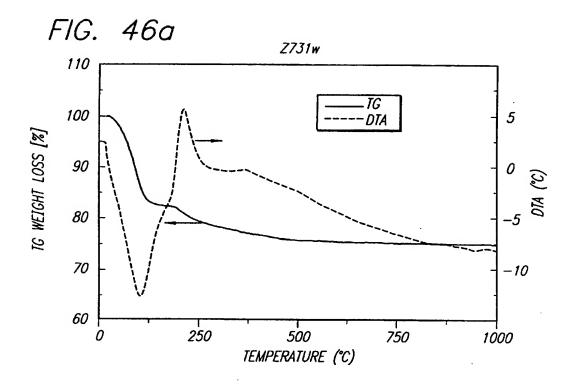


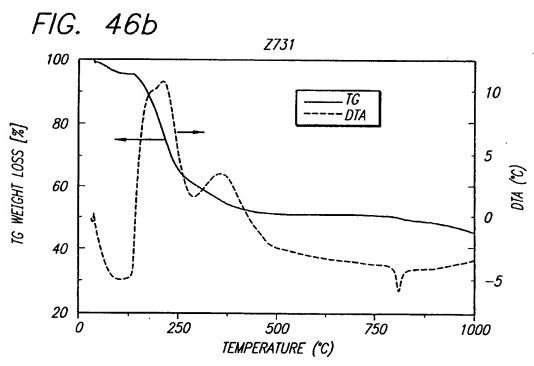
FIG. 45c

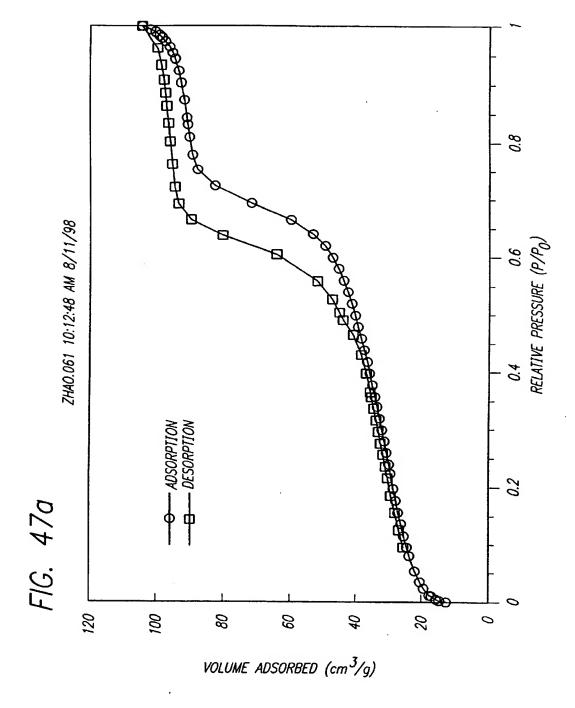


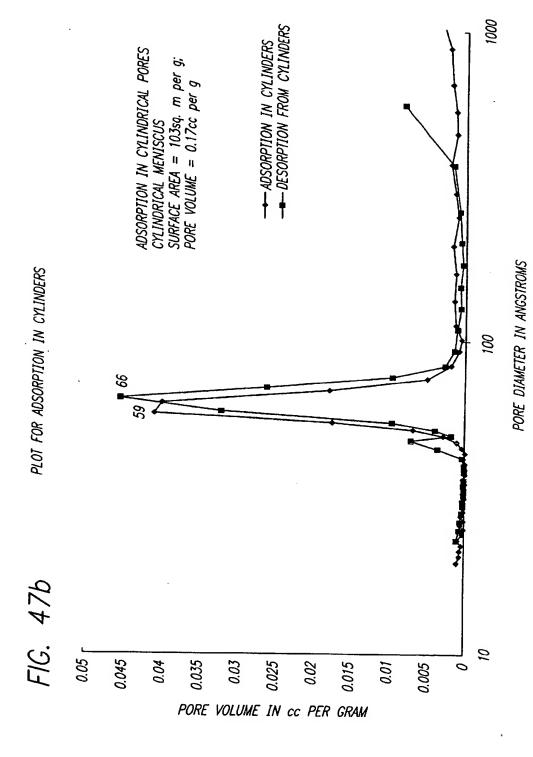
1<u>00 nm</u>

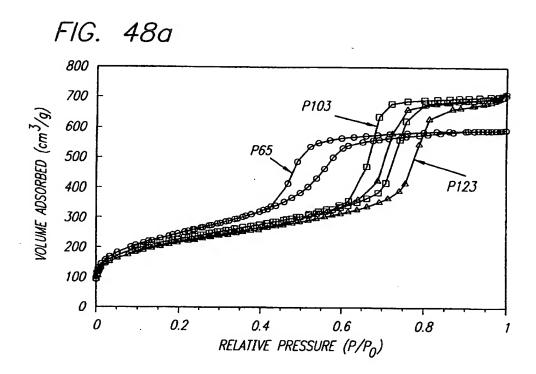
FIG. 45d

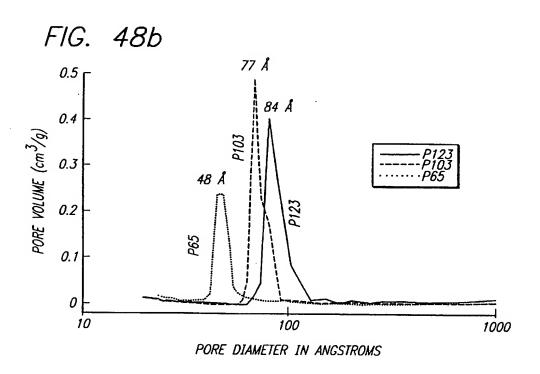


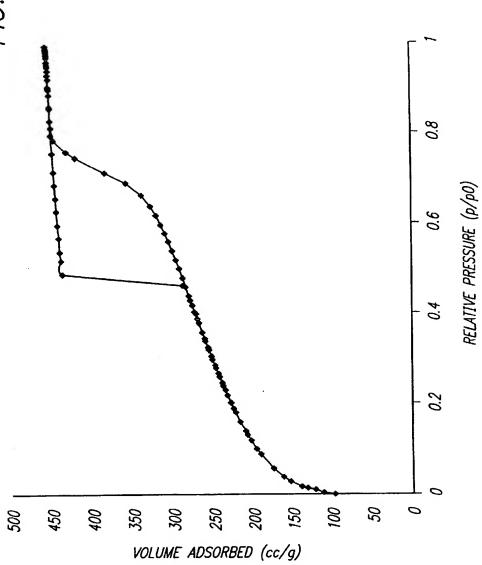


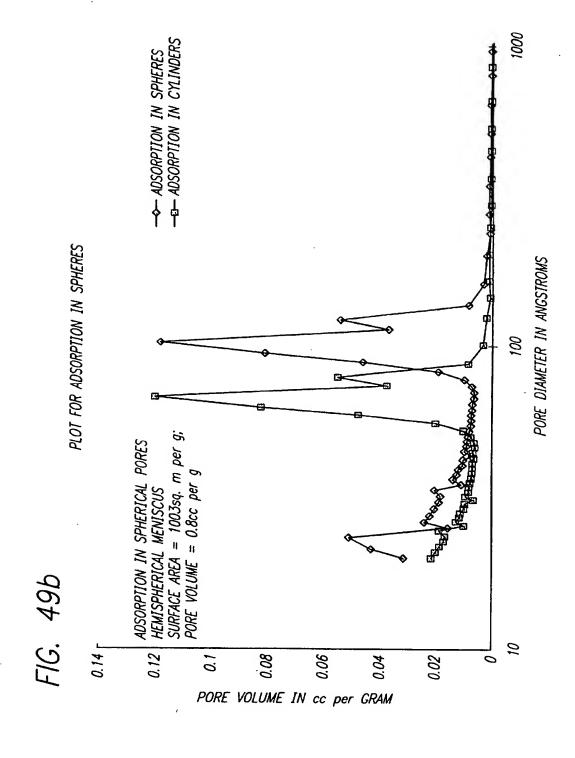


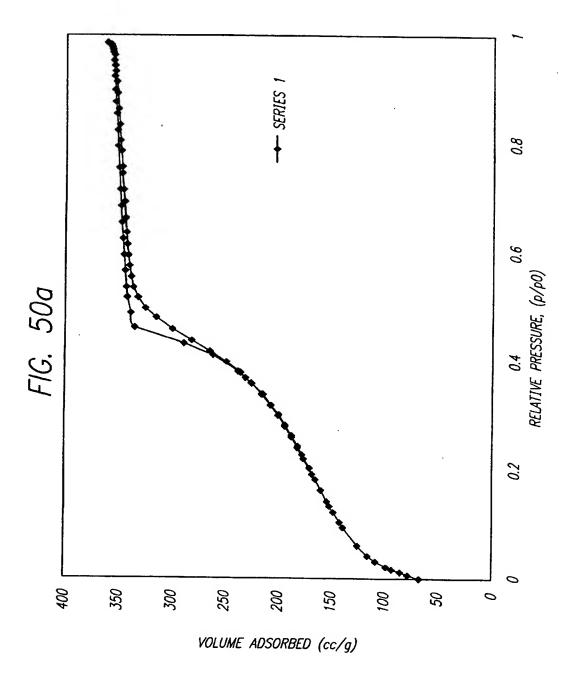


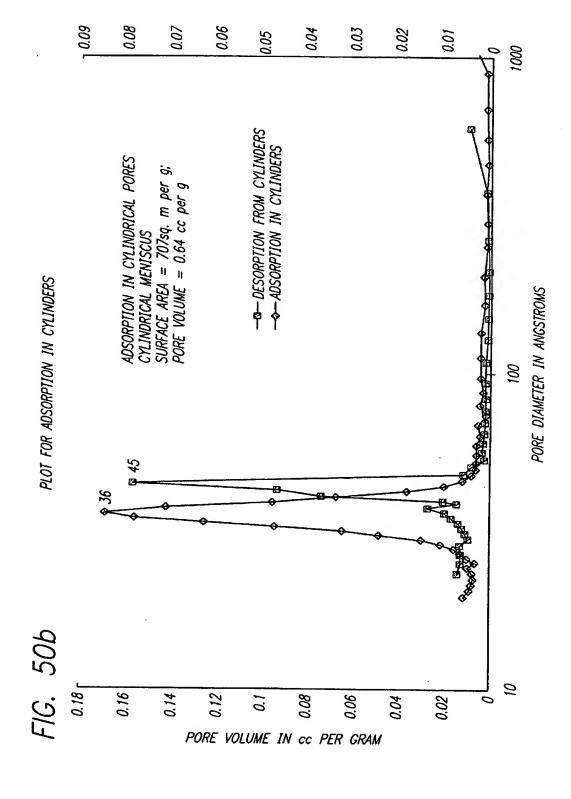


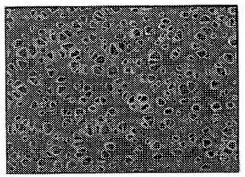






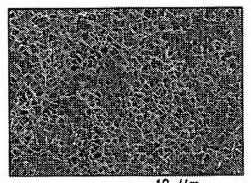






- 1 μ m 3.0 kV X 4.000 12mm

FIG. 51a



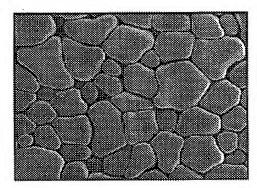
_____ 10 μm 3.0 kV X 1.000 12mm

FIG. 51b



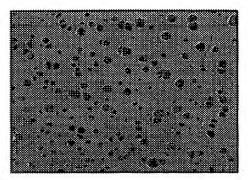
--- 1 μ m 3.0 kV X 20.000 11mm

FIG. 51c



- 10 μm 3.0 kV X 500 11mm

FIG. 51d



3.00 kV X 250 12mm

FIG. 51e

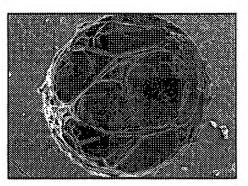
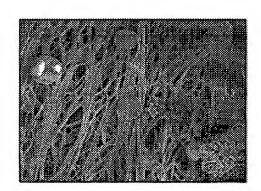
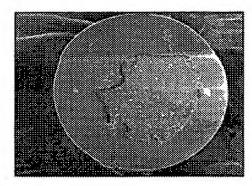


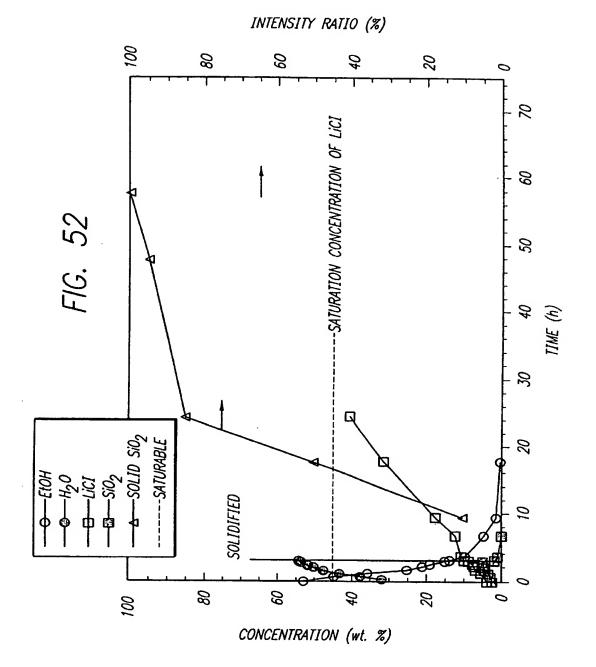
FIG. 51f

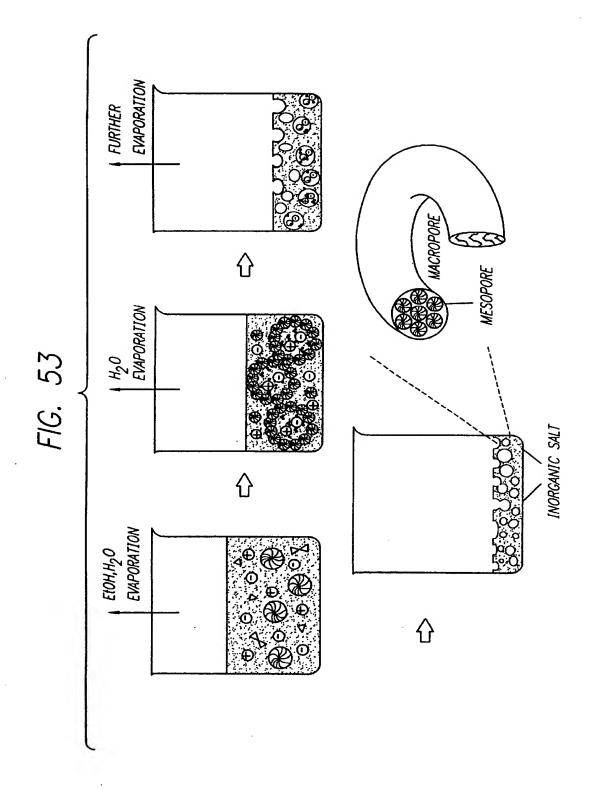


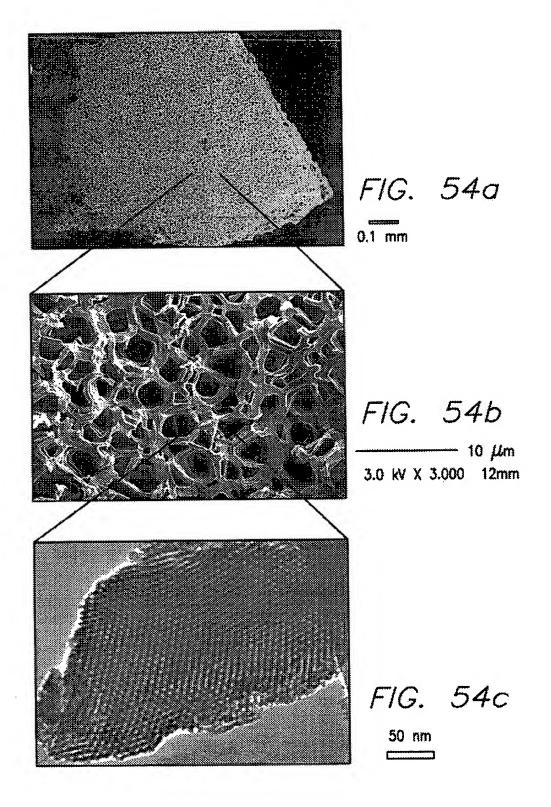
 $\frac{-}{3.00~\text{kV}}$ X $\frac{10~\mu\text{m}}{3.300}$ 12mm

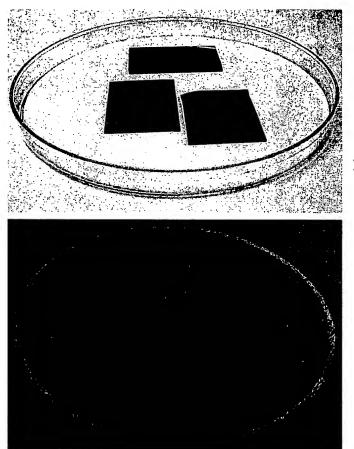
FIG. 51g FIG. 51h











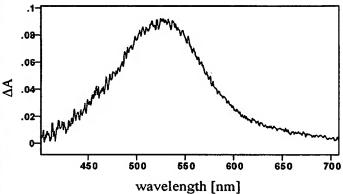


Figure 55. Mesostructured 1 μ m thick, silica/EO₁₀₆PO₇₀EO₁₀₆ optical films under ambient and longwave irradiation. The absorption difference spectrum is for the spiropyran dye (1',3'-Dihydro-1',3',3'-trimethyl-6-nitrospiro[2*H*-1-benzopyran-2,2'-2(*H*)-indole]) employed here and excited under near-UV light (365 nm).

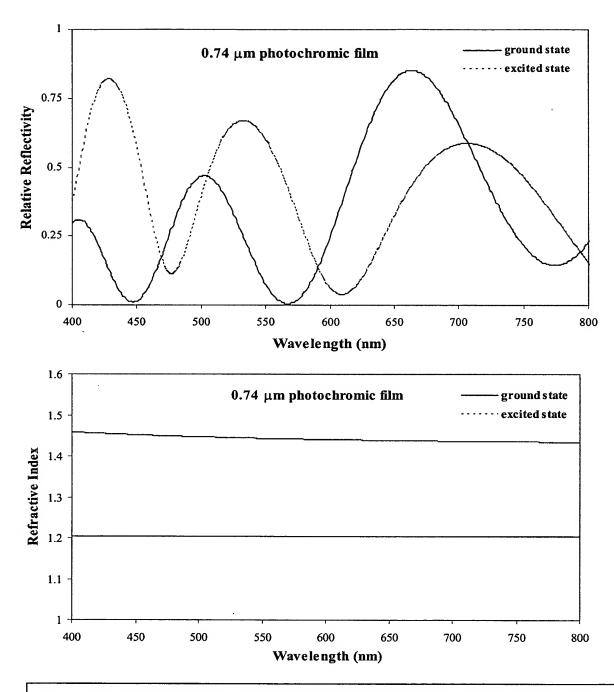
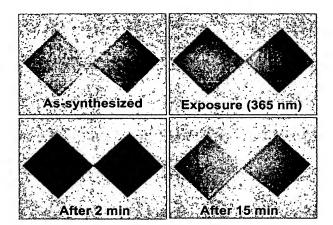
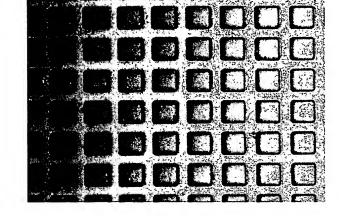


Figure 56. Examples of the observed reflectance spectra and the calculated refractive indices for the mesostructured silica/EO₁₀₆PO₇₀EO₁₀₆ optical film containing the spiropyran dye in the ground state (blue, solid trace) and the excited state (red, dashed trace).





$$\frac{h\nu_1 \text{ or heat}}{h\nu_2} \qquad \frac{\nu}{\nu}$$

Figure 57. Different dynamic responses of patterned films of 55 wt% EO₁₀₆PO₇₀EO₁₀₆-silica composites containing different spiropyran or spiroxazine dye species are shown upon exposure to incident ultraviolet light. Different dye-composite compositions and processing conditions will be explored by using high-throughput synthesis and screening methods, specifically robotic inkjet printing to deposit systematically varying arrays.